THE THERMOLYSIS AND PHOTOLYSIS OF FERROCENYLSULPHONYL AZIDE. EVIDENCE FOR A METAL-NITRENE COMPLEX IN THE THERMOLYSIS.

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(Received in USA 13 March 1971; received in UK for publication 5 April 1971) Though many studies have been carried out on sulphonyl nitrenes (1) little has been reported on the metal-catalyzed decomposition of sulphonyl azides. In view of the effort devoted to the stabilization of electron deficient intermediates by transition metals we have studied the decomposition of ferrocenylsulphonyl azide (1) and report our results which suggest that a metal-nitrene complex is involved in the thermolysis. The results of the thermal and photochemical decomposition of (1) in benzene, cyclohexene and cyclohexane are summarized in Table $1.^{\ddagger}$ These

Fc = Ferrocenyl; $_{\alpha}$ FcSO $_{2}$ NHS = insertion product where HS is solvent, h $_{\nu}$ photochemical at 3500A. Ξ [2]-Ferrocenophane-l,l-dioxid

results show that (1) decomposes <u>via</u> two competing pathways: N-N₂ cleavage to give nitrenes and S-N $_3$ cleavage to give ferrocene, probably derived from the ferrocenyl radical. Thermolysis gives much higher yields of ferrocene than does photolysis; S-N cleavage competes much more favourably with nitrene formation in the thermal process than it does in the photochemical process. The hydrogen abstraction product, $FCSO_2NH_2$ (3) is formed both in thermolysis and photolysis, and indeed is the main product of thermolysis. While hydrogen abstraction has been an important side-reaction of sulphonyl nitrenes (2), it becomes the main pathway in the copper-catalyzed decomposition of benzenesulphonyl azide, and it was suggested (3) that a copper-nitrene complex was involved. Likewise, a drastic increase in the yield of methanesulphonamide was observed when the corresponding aside was decomposed in an aromatic solvent in the presence of transition metal compounds (4) * It thus appears that hydrogen abstraction is an important reaction of metalnitrene complexes. A complex such as (2) , formed by an interaction between the iron atom and the nitrene nitrogen, could account for the high yields of the sulphonamide in the thermal reactions (Scheme I). It is conceivable, however, that

FcS02NHS could arise directly from the free singlet nitrene, a well-documented process (1).

Scheme I

There are several interesting features to the photochemical reaction. The intramolecular cyclisation product, [2]-ferrocenophane-l,l-dioxide (5) is only obtained on photolysis but no intermolecular insertion products FcS02NHS are formed. Oxygen and hydroquinone are without effect on the yield of intramolecular cyclisation product. The sulphonamide (2) formed in photolysis could arise from hydrogen abstraction by the triplet nitrene. Another product formed only on photolysis in cyclohexene is 7-ferrocenylsulphonyl-7-asabicyclo[4.l.O]heptane. The only other example of asiridine formation from a sulphonyl aside has been discussed by Wart and Khan (3) as involving the attack of a copper-nitrene complex generated thermally on cyclohexene. Whether or not photolysis of a metalnitrene complex is involved here is not known. Since the products from the thermolyses and photolyses are so different, however, we are tentatively formulating the photochemical reaction as shown in Scheme II.

Scheme II

Dimethylsulphoxide had a marked effect on both the thermal and the photochemical reaction, and there are no longer any significant differences between them. All the reactions, except for hydrogen abstraction, are suppressed and only a small amount of sulphoximine, FcSO₂N=SMe₂, is formed. The results are **tabulated in Table II.**

Solvent	$h\nu/\Delta$	FCSO2NH ₂	Sulphoximine	FCH
DMSO	Δ	40.6	0.6	2.6
	$h\vee$	38.4	2.0	1.6
c_6H_6 /DMSO	Δ	31.1	\sim	trace
	ħν	39.1	3.4	trace
$c_{6}H_{12}/DMSO$	Δ	17.0	$\overline{}$	trace
c_{6} H ₁₀ /DMSO	hν	54.9	$\overline{}$	trace

Table II. Effect of dimethylsulphoxide on product distribution (% yield)

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*All new compounds have been fully characterized.

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